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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Aaron O. Vanderpool et al.

Serial No.: 10/789,851

Filed: February 26, 2004

For: Implanting Carbon to  
Form P-Type Source  
Drain Extensions

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Art Unit: 2891

Examiner: Asok K. Sarkar

Atty Docket: ITL.1078US  
P18386

Assignee: Intel Corporation

Mail Stop **Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO RESTRICTION REQUIREMENT**

Sir:

In response to the restriction requirement mailed July 15, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: July 21, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

*Cynthia L. Hayden*  
Cynthia L. Hayden